



<p style="text-align: center;">Searched</p> 	<p>Application/Control No.</p> <p>10678920</p>	<p>Applicant(s)/Patent Under Reexamination</p> <p>HWANG ET AL.</p>
	<p>Examiner</p> <p>Detschel, Marissa J</p>	<p>Art Unit</p> <p>2877</p>

Class	SubClass	Date	Examiner
356	495	6/5/06	MJD
356	511-514	6/5/06	MJD

U.S. Patent and Trademark Office	Part of Paper No.: 20060607
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Search Notes 	Application/Control No. 10678920	Applicant(s)/Patent Under Reexamination HWANG ET AL.
	Examiner Detschel, Marissa J	Art Unit 2877

Notes	Date	Examiner
Consulted Hwa Lee on amendment and case	6/5/06	MJD
EAST search for amendments to claims	6/5/06	MJD

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